Structural, Optical and Electrical Properties of Nanostructured CdS:CuS Composite Thin Films Grown by CBD Method


Nanostructured Thin film Materials Laboratory, Departments of Physics, Govt. Vidarbha Institute Sciences and Humanities, Amravati, 444604, Maharashtra, India

Abstract   Synthesis of nanostructured composite chalcogenide materials have been the subject of much interest in basic research because of their photovoltaic applications. The ternary composite semiconducting thin films of CdS:CuS were successfully deposited onto glass substrates at room temperature by Chemical Bath Deposition (CBD) method using cadmium acetate, cupric acetate and sodium thiosulphate in acidic medium. The films were characterized by using X-ray diffraction, scanning electron microscopy, Fourier transform infrared (FTIR) spectrum, optical absorbance, dc electrical resistivity measurements and thermo-emf techniques. The deposited CdS:CuS composite thin films are polycrystalline in nature with hexagonal phase of CdS and CuS with average crystallite size of 23 nm. The optical band gap and activation energy of CdS:CuS thin film is found to be 2.77 and 0.03 eV respectively. The electrical resistivity at 373 K temperature was found to be of the order of 6.87 Ω-cm and it decreases as temperature increases indicating its semiconducting nature. The thermo-emf measurement conforms p-type conductivity of CdS:CuS. The water angle contact measurement conforms hydrophilic nature of CdS:CuS thin films.

Keywords   CdS:CuS Thin Films, CBD Method, Chalcogenide, Optical, Electrical Properties

1. Introduction

In recent years, the development of nanostructured materials in the form of thin films occupy a prominent place in basic research and solid state technology due to their expanding range of potential applications in the diverse field such as photovoltaic cells, electronic components, fabrication of large area photodiode arrays, photoconductors, sensors, antireflection coatings, optical filters, surface acoustic wave devices, solar selective coatings and solar cells etc.[1]. The nanostructured material has high surface area to volume ratio and hence shows different structural, optical, electrical, magnetic and dielectric properties than bulk. A nanostructured thin films material layer can be grown on a substrate by controlled condensation of the individual atomic, molecular or ionic species either directly by a physical process or through a chemical and/or electrochemical reaction. The application of nanostructured thin films can be utilized to enhance the efficiency of semiconductor or photovoltaic devices as well as to lower their effective cost. In this regard many nano-structured materials are now being investigated for their potential applications in photovoltaics[2].

Cadmium sulphide(CdS) and copper sulphide(CuS) thin films have received great importance since the historic discovery of the photovoltaic properties of CuS thin films in contact with CdS thin films[3]. It is well known that the electrical and optical properties of CdS and CuS thin films play potential role in photoconductors, photovoltaic devices, solar selective coatings, IR detectors etc. Several techniques have been investigated to prepare CdS and CuS thin films. Lokhande[4] have deposited CdS thin films by chemical bath deposition method using sodium thiosulphate as sulphur source in acidic medium. The optical band gap and electrical resistivity of the as-deposited thin films is of the order of 2.55 eV and 10^3-10^4 Ω-cm respectively. Mahdi et al.[5] have prepared adhesive homogenous CdS nanocrystalline thin films using microwave assisted chemical bath deposition method onto glass substrate at 80°C and studied their structural and optical properties. Jaber et al.[6] have deposited CdS thin films by chemical bath deposition technique using ethanolamine as a complexing agent instead of commonly used ammonia to avoid toxicity and volatility during film preparation. The optical transmittance characterization in UV-Visible range...
shows that the prepared films have a high transparency ranging from 60 to 80% for photons having wavelength greater than 600 nm. Jatar et al. [7] have prepared Al doped CdS thin films by vacuum evaporation technique and discussed their utility in liquid crystal display. Ashour [8] have prepared cadmium sulphide(CdS) thin films by chemical spray pyrolysis technique by varying the substrate temperature in the range of 200-400°C and reported their physical properties. Lokhande and Pawar [9,10] have deposited aluminium doped and undoped CdS films on stainless steel substrate by chemical bath deposition technique and studied their electrochemical properties. Lokhande et al. [11] have deposited copper doped and undoped CdS films on stainless steel strips by chemical bath deposition. Ubale et al. [12] have prepared CuS thin films by chemical route at room temperature and reported their size dependent physical properties. Nair et al. [13] have reported the optoelectronic and solar properties of chemically deposited CuS thin films. Fatas et al. [14] have deposited CuS thin films in alkaline medium by chemical method using CuSO₄ and thiourea as cationic and anionic source. The optical band-gap is 2.58 eV and electrical resistivity is of the order of 3 x 10⁻³ Ω-cm. Lindroos et al. [15] have prepared polycrystalline copper sulphide thin films by successive ionic layer adsorption and reaction method at room temperature.

Now a day’s nanostructured thin films had been studied with the expectation that the new enhanced properties exhibited by various composite materials were useful in various semiconductor devices especially in photovoltaic cells. Although number of reports were available on chemically deposited ternary composite thin films such as HgS–Bi₂S₃ [16], (NiS)(CdS)₁−x [17], (CdS)x(PbS)₁−x [18], PbS–Cu₂S [19], Bi₂S₃–CuS [20,21], Cd₁−xZnxS [22–25], Cd₁−xFe₄S [26], (CdS)x(Bi₂S₃)₁−x [27], and reported their potential applications in the range of areas including solar control coating, energy conversion and solar energy utilization, still there is a wide spread interest owing to the variation in structural, electrical and optical properties of nanostructured semiconductor thin films due to their novelty; their properties are different and superior than conventional polycrystalline materials which are very important for semiconductor application.

Literature survey reveals that many reports are available on CdS and CuS thin films prepared by CBD method. The present paper deals with the synthesis of nanocrystalline CdS:CuS composite thin films at room temperature by CBD method. Among the various deposition techniques chemical bath deposition (CBD) techniques has attracted much attention of research community as it is a simple and cost effective for deposition of homogeneous and high-quality nanostructured thin films at room temperature. It does not require any sophisticated instrument like vacuum system. The films deposited by this method are uniform and continuous as the solution remains in contact with substrate throughout the process. The various preparative parameters such as pH, ionic concentration, deposition time etc. can be easily controlled to get good quality thin films. The growth of thin film strongly depends on the growth conditions, such as duration of deposition, composition and temperature of solution and topographical and chemical nature of the substrate. The preparative parameters such as ionic concentration of Cd, Cu and sulphur, temperature and pH were optimized to get good quality thin films on glass substrate. The composition dependent structural, morphological, optical and electrical properties of CdS:CuS thin films were studied by X-ray diffraction, scanning electron microscopy, optical absorbance and electrical resistivity measurements.

2. Experimental

Chemical bath deposition is a simple and attractive method for the fabrication of nanostructured metal chalcogenide thin films which is also known as solution growth, controlled precipitation, or simply chemical deposition. The reaction takes place between the dissolved precursors generally in aqueous solution at low temperature. The sulphide precursors such as thiourea, thioacetamide, thiosulphate and sodium sulphide are generally used.

In CBD method substrate cleaning is very important as it is one of the factors determining the composition and grain size of the film. There are various cleaning methods depending on the nature of the substrate, type of contaminants and the extent of cleanliness required for thin film deposition. The surface of the substrate will be usually contaminated with fingerprints, oil, lint and dust. In present investigation, the amorphous glass substrates of approximately 100% transmission and size (75 mm x 25 mm x 1.35 mm) supplied by polar industrial corporation (blue star), Mumbai were utilized for deposition purpose. The glass substrates were boiled in the chromic acid for 30 minutes and kept in it for next 48 hours. The slides were then dipped in labolene detergent and washed with double distilled water. Finally the slides were cleaned with ultrasonic cleaner for 10 minutes, dipped in AR grade acetone and dried for 15 min, prior to the deposition.

For deposition of CdS:CuS composite thin films by chemical bath deposition, an aqueous solution of cadmium acetate, cupric acetate and sodium thiosulphate were used in acidic medium. For this, 20 ml (0.1M) cadmium acetate (CH₃COO)₂Cd·2H₂O), 20 ml (0.1M) cupric acetate (C₂H₅CuO₂·H₂O) and 40 ml (0.1M) sodium thiosulphate (Na₂S₂O₃·5H₂O) were mixed in 100 ml beaker at room temperature. Then the concentrated HCL was added drop wise in the reaction mixture to adjust pH to 3. The prepared solution was stirred continuously for 5 minutes to obtain a homogenous solution. The cleaned glass substrates were then immersed into the resultant solution and suspended vertically with the help of specially designed holder. The colour of solution was changed after about 60 min, which indicates initiation of the chemical reaction. The substrate covered with an orange-yellow deposit, were taken out from
the bath after 12 hours deposition time, rinsed with distilled water and allowed to dry in air. The thickness of the composite CdS:CuS thin film was measured by weight difference method using the relation,

\[ t = \frac{m}{\rho \cdot A} \] (1)

Where \( m \) is the mass of the deposited film on the substrate which covers area \( A \) (cm\(^2\)) and \( \rho \) is the average bulk density of CdS and CuS (4.73 g/cm\(^3\)). In present investigation thickness of CdS:CuS films measured using sensitive microbalance was found to be 262 nm. The structural properties of the CdS:CuS composite thin films were studied by a PANalyticalX’Pert PRO MRD X-ray diffractometer with CuK\(\alpha\) radiation of wavelength 0.154 nm. Surface morphological analyses of thin films deposited on glass substrates were performed using JOEL’S JSM-7600F scanning electron microscope. The FTIR analysis of CdS:CuS composite thin films deposited on glass substrate were carried out by FTIR shimadzu spectrometer IR Afffinity-1 in the wavenumber range 400-4000 cm\(^{-1}\). Optical absorption studies were carried out using a UV–Vis spectrophotometer (Perkin Elmer, Lambda 25) in the wavelength range 300–1100 nm. The optical spectra were recorded for the film deposited on glass substrate. This data was further analyzed for the estimation of band gap energy of the thin film. The electrical resistivity measurements were carried out using the dc two point probe method in the temperature range 303–443 K. The electrical contacts to the film surface were made using silver paste.

To study temperature dependent resistivity measurements, strip heaters were used to heat sample and chromel–alumel thermocouple was used to measure the temperature of the sample. The type of electrical conductivity of the film was determined by measuring thermo-emf developed across the sample due to application of temperature gradient.

3. Results and Discussion

3.1. Reaction Mechanism

The reaction mechanism for deposition of the metal sulphide films from an acidic bath using Na\(_2\)S\(_2\)O\(_3\) as a sulphur source has previously been reported[28-30]. The deposition of (CdS:CuS) composite thin film is based on the slow release of Cd\(^{2+}\), Cu\(^{2+}\) and S\(^{2-}\) ions in the solution, which are then condensed onto the glass substrates. Cadmium acetate (CH\(_3\)COO)\(_2\)Cd.2H\(_2\)O and cupric acetate (C\(_6\)H\(_5\)CuO\(_4\).H\(_2\)O) were used as sources for Cd\(^{2+}\) and Cu\(^{2+}\) ions. The reaction mechanism for the deposition of composite CdS:CuS thin film is proposed as follows. In aqueous solution, Na\(_2\)S\(_2\)O\(_3\) dissociates as,

\[ \text{Na}_2\text{S}_2\text{O}_3 \rightarrow 2\text{Na}^+ + \text{S}_2\text{O}_5^{2-} \] (2)

Na\(_2\)S\(_2\)O\(_3\) is a reducing agent by virtue of the half-cell reaction,

\[ 2\text{S}_2\text{O}_5^{2-} \rightarrow \text{S}_4\text{O}_6^{2-} + 2e^- \] (3)

In acidic medium, dissociation of Na\(_2\)S\(_2\)O\(_3\) takes place,

\[ \text{S}_2\text{O}_5^{2-} + \text{H}^+ \rightarrow \text{HSO}_3^- + \text{S} \] (4)

The electron released in equation (3) reacts with sulphur,

\[ S + 2e^- \rightarrow S^{2-} \] (5)

The cations Cd\(^{2+}\) and Cu\(^{2+}\) reacts with anions S\(^2-\) in the solution to give CdS:CuS as,

\[ \text{Cd}^{2+} + \text{Cu}^{2+} + 2\text{S}^{2-} \rightarrow (\text{CdS}) : (\text{CuS}) \] (6)

3.2. Structural Properties

The structural identification of CdS:CuS composite thin film was carried out from the analysis of the X-ray diffraction pattern taken in the range of 20 between 20° and 80°. Figure 1 shows the X-ray diffraction pattern of CdS:CuS composite film deposited on glass substrate. The diffraction pattern of CdS:CuS composite thin film shows polycrystalline nature with mixed hexagonal lattice due to CdS and CuS. The observed 20 and d values are in good agreement with earlier reports[31, 32, 33]. The electron released in equation (3) reacts with sulphur,

\[ S + 2e^- \rightarrow S^{2-} \] (5)

The cations Cd\(^{2+}\) and Cu\(^{2+}\) reacts with anions S\(^2-\) in the solution to give CdS:CuS as,

\[ \text{Cd}^{2+} + \text{Cu}^{2+} + 2\text{S}^{2-} \rightarrow (\text{CdS}) : (\text{CuS}) \] (6)

3.3. SEM Studies

Scanning electron microscopy is a convenient method to study the surface morphology of thin films. Surface morphology of material plays an important role in solar energy conversion efficiency of the device. The SEM micrographs of as-deposited CdS:CuS composite thin film
(thickness ~ 262 nm) on glass substrate at X100,000 and X50,000 magnification is shown in figure 2. The CdS:CuS thin film has dense, homogeneous and porous growth morphology. The nanosized grains are uniformly distributed throughout the surface. The grains are quite small with unequal size and shape, also their boundaries are not well defined, and hence it was difficult to calculate the exact average value of grain size from SEM image. The film surface shows spherical flower-like hierarchical morphology with overgrowth. Such flower like morphology was represented by Lihua Wang et al.[34] for chemically deposited CuS thin films. Also, Figure 2(B) shows growth of nanoleaflets on spherical grain; that increases the surface to volume ratio of deposited CdS:CuS material, which can be potential utilized in many optoelectronic and photovoltaic devices.

3.4. Fourier Transforms Infrared Analysis

Fourier Transform-Infrared Spectroscopy (FTIR) is an analytical technique used to identify organic as well as inorganic materials. This technique measures the absorption of infrared radiation by the sample material versus wavelength. The FTIR spectrum of CdS:CuS composite thin film is as shown in Figure 3. FTIR measurements have been made in the wave number range 400 cm\(^{-1}\) to 4000 cm\(^{-1}\).

The peak locations related to the corresponding chemical bonds are in good agreement with those reported in the literature[35, 36]. The weak absorption band at 3730.33 cm\(^{-1}\) is assigned to O-H stretching vibration of the adsorbed water in the sample. The presence of water is also confirmed by its bending vibration observed at 1672.28 cm\(^{-1}\). Medium strong band position at 1406.11 cm\(^{-1}\) is possibly due to stretching vibrations of sulphate group. The absorption bands observed at 569.00 cm\(^{-1}\) and 686.66 cm\(^{-1}\) are possibly due to Cd-S stretching. The absorption near 1880.60 cm\(^{-1}\) may be due to C=C vibration suggesting organic contamination from the source materials. Any band due to CuS is not observable in the IR spectra as the compound is IR-inactive[37]. From figure 2 it can be seen that almost all absorption values of composite CdS:CuS are shifted to either higher or lower values as compared to CdS. This indicates that nano-sized CdS has affected the absorption phenomena in the IR region due to formation of composite CdS:CuS.

3.5. Optical Properties

The study of optical properties of thin films has special significance in the world of science, technology and industry for the development of new optical devices. Optical absorption study of materials provides useful information to analyze some features concerning the band structure of materials. The optical band gap energy of the semiconductor is an important parameter that plays a major role in the construction of photovoltaic cells. In present report optical properties of the nano-composite CdS:CuS film deposited on glass substrate was studied from the absorption spectra measured by a UV–Vis spectrophotometer lambda 25 in the wavelength range 300 to 1100 nm by subtracting the absorption of the glass substrate, which was
taken as a reference. The variation of absorbance (αt) with wavelength (nm) for CdS:CuS thin film is shown in figure 4. The sharp absorption edge observed confirms the good optical band edge property of the CdS:CuS thin film. The fundamental absorption, which corresponds to electron excitation from the valance band to conduction band, can be used to determine the nature and value of the optical band gap.

The nature of transition is determined by using the relation,

\[ \alpha h\nu = A(h\nu - E_g)^n \]  

Where A is constant, \( h\nu \) is photon energy and \( E_g \) is the optical band gap. The exponent \( n \) depends on the nature of the transition, \( n=1/2, 2, 3/2 \) or 3 for allowed direct, allowed indirect, forbidden direct or forbidden indirect transitions, respectively. For determination whether the film has direct or indirect band gap, a plot of \( (\alpha h\nu)^2 \) vs. \( h\nu \) is plotted, where \( \alpha \) is the optical absorption coefficient and \( h\nu \) is the photon energy. In present case better linearity (Figure 5) was observed and it confirms that the film has a direct band transition. By extrapolating the linear portion of the curve to photon energy axis for zero absorption coefficient, the intercept of the curve i.e. the optical band gap of CdS:CuS thin film estimated and found to be 2.77 eV. However, the literature shows that the optical band gap of CBD deposited CdS thin films reported by Wenyi et al.[38] and Cortes et al.[39] is of the order of 2.56 to 2.33 and 2.35 to 2.48 eV respectively. Also the optical band gap of CBD deposited CuS reported by Gadve et al.[40] and Grozdanov et al.[41] is 2.40 and 2.58 eV respectively. The reported values of \( E_g \) for CdS and CuS are quite less than our estimated value 2.77 eV for composite CdS:CuS. It is well known that the band gap energy depends upon the films composition, crystal structure, particle size and strain in the film. Also the electronic particles, confined by potential barriers to a space comparable or smaller than the De Broglie wavelength of the particles, have discrete allowed energy states rather than a continuum. For bulk materials the density of states is a continuous function, but when confinement appears quantisation arises, and thus for quantum films it becomes a step function showing higher value of ‘\( E_g \)’ as compare to bulk.

3.6. Electrical Properties

The current–voltage (I–V) characteristics of the as-deposited thin film was studied in dark to check nature of contact of CdS:CuS with silver using two-probe method. The typical IV characteristics for CdS:CuS thin films is shown in figure 6.

These measurements were carried out in between 1V to 10V. The I–V characteristic for CdS:CuS thin film is found to be linear, indicating the ohmic contact of electrodes with aggregated film. The electrical resistivity of any conductor depends on the material of which it is composed of and the
temperature. As the characteristic property of any material, resistivity is most useful in comparing various materials on the basis of their ability to conduct electric current. The electrical resistivity of CdS:CuS thin film at 303K temperature is of the order of 8.28 Ω-cm. The resistivity of chemically deposited CdS thin films reported by Sankapal et al.[32] is of the order of 10^5 Ω-cm and that of CuS reported by Sartale et al.[42] is of the order of 10^2 Ω-cm. The resistivity of CdS:CuS is found in between these two values which confirms the formation of composite. The variation of dark dc-electrical resistivity of CdS:CuS thin film was studied in the temperature range 303 to 443 K using dc two-point probe method. The variation of logarithm of electrical resistivity with reciprocal of temperature is as shown in figure 7. It is seen that resistivity decreases with rise in temperature indicating semiconducting character of CdS:CuS thin films. The electrical resistivity of CdS:CuS follows the relation,

\[ \rho = \rho_0 \exp \left( \frac{E_0}{kT} \right) \]  

(9)

Where \( \rho \) is the resistivity at temperature T, \( \rho_0 \) is a constant, K is Boltzmann’s constant and \( E_0 \) is activation energy required for conduction. The activation energy estimated from the resistivity plot is found to be 0.03 eV for as-deposited CdS:CuS composite thin film.

3.7. Thermo-emf Studies

The thermoelectric materials have utilized to convert temperature gradient into electricity based on the Seebeck and Peltier effects. The thermo-emf studies were carried out in the temperature difference range of 326 to 421 K for obtaining the information about the type of conductivity in CdS:CuS composite thin films. The transport of carriers from the hot end to cold end of sample due temperature difference between two ends of the sample creates the electric field, which generates the thermo-emf across the ends of sample. It is observed that the thermo-emf generated is directly proportional to the temperature gradient maintained across composite film. The temperature difference of 421 K applied across the ends of the sample the generated emf was 63.1 mV (figure 8). The type of conductivity was decided from the sign of the emf generated at the cold and hot end. In present study the negative terminal was found to be at the hot end; showing p-type conductivity of CdS:CuS thin film.

3.8. Surface Wettability

The wettability behavior is characterized by the value of contact angle; a macroscopic parameter. Contact angle measurement involves the interaction between a liquid and a solid in contact. The surface water contact angle is directly related to the presence of chemical composition, local inhomogeneities and surface morphology in thin film. Here we have calculated mean value of water contact angle by repeating experiment at different positions. Figure 9 shows the water contact angle of CdS:CuS. The measurement of water contact angle on its surface is an empirical diagnostic method for evaluation of thin film property. For as-deposited CdS:CuS composite thin film, water contact angle of 40° was observed which confirms the hydrophilic nature of the CdS:CuS thin film surface. From SEM images it is confirmed that due to porous hierarchical morphology, the water placed on the surface of the film goes inside the pores as a result contact angle is reduced, which is suitable for making the intimate contact with aqueous electrolytes in electrochemical application.
4. Conclusions

In present paper, we have reported the simple and convenient chemical bath deposition (CBD) method for the synthesis of nanostructured CdS:CuS composite thin films of thickness 262 nm using cadmium acetate, cupric acetate and sodium thiosulphate in acidic medium. The XRD analysis revealed that the CdS:CuS composite film is polycrystalline in nature with hexagonal crystal structure with crystallite size around 23 nm. The SEM studies show the uniform and porous hierarchical morphology suitable for many applications. FTIR analysis explains different bends present in CdS-CuS nanomaterial. The optical direct band-gap energy of film was found to be 2.77 eV. The dc electrical resistivity measurement showed that the CdS:CuS composite films are semiconducting in nature with activation energy 0.03 eV. The measurement of thermo-emf confirms p-type conduction mechanism of CdS:CuS composite thin film. The water contact angle measurement confirms hydrophilic nature of CdS:CuS thin films, which will be suitable for making contact with aqueous electrolytes in electrochemical cells.

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